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DATE MAILED: 05/17/2004

	APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
G	10/655,705	09/05/2003	Chia-Shun Hsiao	M-12953US	7164
	7590 05/17/2004			EXAMINER	
	David S. Park MacPHERSON KWOK CHEN & HEID LLP) LLP	GEYER, SCOTT B	
	Suite 226	TEN OIL OILEN & HEIL	<i>222</i> 1	ART UNIT	PAPER NUMBER
	1762 Technolog San Jose, CA		*	. 2829	*

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
Office Action Series	10/655,705	HSIAO ET AL.				
Office Action Summary	Examiner	Art Unit				
	Scott B. Geyer	2829				
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the	correspondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be till y within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from CAUSE the application to become ABANDONE	nely filed ys will be considered timely. the mailing date of this communication.				
Status						
1) Responsive to communication(s) filed on 05 Se	eptember 2003.					
2a) ☐ This action is FINAL . 2b) ☑ This action is non-final.						
3) Since this application is in condition for allowar closed in accordance with the practice under E						
Disposition of Claims						
4)⊠ Claim(s) <u>1-29</u> is/are pending in the application.	N .					
4a) Of the above claim(s) is/are withdraw	•					
5) Claim(s) is/are allowed.	vii ii oiii consideration.					
6) Claim(s) is/are rejected.		* <u>.</u>				
7) Claim(s) is/are objected to.						
8) Claim(s) 1-29 are subject to restriction and/or e	election requirement.	·				
Application Papers	•					
9) The specification is objected to by the Examiner						
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a) All b) Some * c) None of:	have been made to	•				
 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 						
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).						
* See the attached detailed Office action for a list of the certified copies not received.						
		-				
		•				
Attachment(s)						
1) Notice of References Cited (PTO-892)	4) Interview Summary	(PTO-413)				
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)	Paper No(s)/Mail Da	ate				
Paper No(s)/Mail Date	6) Other:	atent Application (PTO-152)				
Patent and Trademark Office						

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DETAILED ACTION

Election/Restrictions

- 1. Restriction to one of the following inventions is required under 35 U.S.C. 121:
- Claims 1-25, drawn to a method of making a semiconductor device, classified in class 438, subclass 142+.
- Claims 26-29, drawn to a semiconductor device, classified in class 257, subclass 499.

The inventions are distinct, each from the other because of the following reasons:

- 2. Inventions I and II are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make other and materially different product or (2) that the product as claimed can be made by another and materially different process (MPEP § 806.05(f)). In the instant case, the device (product) as claimed can be made by a materially different method, since the device as claimed does not recite sidewall spacers.
- 3. Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.
- 4. Because these inventions are distinct for the reasons given above and the search required for Group II is not required for Group I, restriction for examination purposes as indicated is proper.

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5. This application contains claims directed to the following patentably distinct species of the claimed invention. If applicant chooses to elect <u>Group I</u> claims above, then the following species elections <u>must</u> be made - -

6. The applicant must elect <u>one</u> from <u>each</u> of the following lettered groups for prosecution:

A. Method of making device

- 1. Method as outlined by figures 2A-2K
- 2. Method as outlined by figures 3A-3D, similar to that outlined by figures 2A-2K, except that a photo-resist mask is not used to make the spacers, as opposed to that which is used as detailed in figure 2G.

B. Nitride layer deposition (from page 9)

- 1. Formed by LPCVD
- 2. Formed by PECVD
- 3. Formed by RTCVD

C. Nitride layer removal (from page 10)

- 1. Hot phosphoric acid
- 2. Oxide ashing

D. Spacer layer composition (from page 11-12)

- 1. Organic material
- 2. Inorganic material

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E. Spacer formation method

- 1. dry etch physical process
- 2. dry etch chemical process
- 3. dry etch combination of chemical and physical processes
- 7. Applicant is required under 35 U.S.C. 121 to elect a single disclosed species for prosecution on the merits to which the claims shall be restricted if no generic claim is finally held to be allowable. Currently, none of the claims are generic.
- 8. Applicant is advised that a reply to this requirement must include an identification of the species that is elected consonant with this requirement, and a listing of all claims readable thereon, including any claims subsequently added. An argument that a claim is allowable or that all claims are generic is considered nonresponsive unless accompanied by an election.
- 9. Upon the allowance of a generic claim, applicant will be entitled to consideration of claims to additional species which are written in dependent form or otherwise include all the limitations of an allowed generic claim as provided by 37 CFR 1.141. If claims are added after the election, applicant must indicate which are readable upon the elected species. MPEP § 809.02(a).
- 10. Should applicant traverse on the ground that the species are not patentably distinct, applicant should submit evidence or identify such evidence now of record showing the species to be obvious variants or clearly admit on the record that this is the case. In either instance, if the examiner finds one of the inventions unpatentable over

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the prior art, the evidence or admission may be used in a rejection under 35 U.S.C. 103(a) of the other invention.

- 11. Applicant is advised that the reply to this requirement to be complete must include an election of the invention to be examined even though the requirement be traversed (37 CFR 1.143).
- 12. Applicant is reminded that upon the cancellation of claims to a non-elected invention, the inventorship must be amended in compliance with 37 CFR 1.48(b) if one or more of the currently named inventors is no longer an inventor of at least one claim remaining in the application. Any amendment of inventorship must be accompanied by a request under 37 CFR 1.48(b) and by the fee required under 37 CFR 1.17(i).

Conclusion

13. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Scott B. Geyer whose telephone number is (571) 272-1958. The examiner can normally be reached on weekdays, between 10:00am - 6:30pm. E-mail: scott.geyer@uspto.gov

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Kamand Cuneo can be reached on (571) 272-1957. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

SBG

May 6, 2004

Paresh Patel)
05/07/04